L Number	Hits	Search Text	DB	Time stamp
1	5	(trench with (etch etching) and ((oxide dioxide) and nitride) with mask and removing with mask) and	USPAT; US-PGPUB;	2004/07/28 10:29
		((438/222,226,357,360,363,429,442,for.167,for.221).CCLS.)	EPO; JPO;	
		and @pd>=20040108	DERWENT;	
		and Gpas - 200 10100	IBM_TDB	
2	0	(amorphizing amorphization amorphized amorphous) with	USPAT;	2004/07/28 10:29
_	· ·	(ion implant implantation implanting implanted) same	US-PGPUB;	200 1, 07, 20 20125
		(trench groove recess recessed grooved) and	EPO; JPO;	
		((438/222,226,357,360,363,429,442,for.167,for.221).CCLS.)	DERWENT;	
		and @pd>=20040108	IBM_TDB	
3	2	(amorphizing amorphization amorphized amorphous) with	USPAT;	2004/07/28 10:29
5	_	(ion implant implantation implanting implanted) and	US-PGPUB;	
		((438/222,226,357,360,363,429,442,for.167,for.221).CCLS.)	EPO; JPO;	
i		and @pd>=20040108	DERWENT;	
		and wpd> -200 10100	IBM_TDB	
_	220	(amorphizing amorphization amorphized amorphous) with	USPAT;	2004/07/28 10:28
-	220	(ion implant implantation implanting implanted) same	US-PGPUB;	2001/0//20 20:20
		(trench groove recess recessed grooved) and (438/\$6	EPO; JPO;	
		257/\$6)	DERWENT;	
		237/\$0)	IBM_TDB	
-	112	(amorphizing amorphization amorphized amorphous) with	USPAT;	2004/07/28 08:38
	112	(ion implant implantation implanting implanted) with (trench	US-PGPUB;	2001/07/20 00:50
		groove recess recessed grooved) and (((amorphizing	EPO; JPO;	
		amorphization amorphized amorphous) with (ion implant	DERWENT;	
		implantation implanting implanted) same (trench groove	IBM_TDB	
		recess recessed grooved) and (438/\$6 257/\$6)))	1011_100	
	49	(amorphous) near4 (layer film si silicon) with (deposit\$4	USPAT;	2004/07/28 08:40
-	73	cvd) and (((amorphizing amorphization amorphized	US-PGPUB;	200 1, 07, 22 22 12
		amorphous) with (ion implant implantation implanting	EPO; JPO;	
		implanted) with (trench groove recess recessed grooved)	DERWENT;	
		and (((amorphizing amorphization amorphized amorphous)	IBM_TDB	
		with (ion implant implantation implanting implanted) same	15.1_155	
		(trench groove recess recessed grooved) and (438/\$6		
		257/\$6)))))		
_	2	("20020094678").PN.	USPAT;	2004/07/28 08:53
			US-PGPUB;	, , , , , , , , , , , , , , , , , , , ,
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
_	1	jp-07130679-\$.did.	USPAT;	2004/07/28 10:03
		JP 07 200075 \$1000.	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
			IBM_TDB	
_	2	("6537873").PN.	USPAT;	2004/07/28 10:03
		(0007070 /11111	US-PGPUB;	
			EPO; JPO;	
			DERWENT;	
	1		IBM_TDB	